

**ELEG 646; ELEG 446 - Nanoelectronic Device Principles – Spring 2005**  
**Homework #4 - due Tuesday, 22 March 2005, in class**

1.

A 0.5- $\mu\text{m}$  thick sample of GaAs at 300 K has an area of 1  $\text{cm}^2$ . The sample is uniformly illuminated with monochromatic light of  $h\nu = 2.1$  eV. The absorption coefficient  $\alpha$  at this wave length is  $4 \times 10^4$   $\text{cm}^{-1}$ . The power incident on the sample is 12 mW. (a) Calculate the power absorbed by the sample; (b) determine how much power is dissipated by the excess electrons to the lattice before recombining; and (c) determine the number of photons per sec falling on the sample and the number of photons per sec emitted from the electron-hole pair recombination.

2. Let the sample in Prob. 1 (above) be n-type with  $n_o = 10^{16}$   $\text{cm}^{-3}$ . (a) Assuming that each of the absorbed photons produce one electron-hole pair in the sample, calculate the excess electron and hole concentrations in the steady state. (b) Calculate the photoconductivity (see problem 3 below) of the sample and determine whether it is the case of low- or high-level injection. Use the data from Table 1.3 for GaAs.

3.

A homogeneous semiconductor bar is illuminated uniformly by a penetrating light that generates electron-hole pairs at a constant rate  $G_L$   $\text{cm}^{-3} \text{sec}^{-1}$ . Assuming low-level injection, (a) calculate the excess carrier concentration as a function of time if the light is switched on at  $t = 0$ ; and (b) determine the steady state values of electron and hole concentrations and show that the photo conductivity  $\Delta\sigma$  of the sample is given by  $\Delta\sigma = q(\mu_n + \mu_p)G_L\tau_p$ .

4.

For a semiconductor with indirect recombination characterized by a single trap level at  $E_t$  and  $\tau_{po} = \tau_{no}$ , show that under low-level injection the maximum possible lifetime occurs when  $E_F$  lies at  $E_t$ , and that this maximum is given by

$$\tau_p = \tau_{po} \left[ 1 + \cosh\left(\frac{E_t - E_i}{kT}\right) \right]$$

5.

Excess carriers are injected in a region of a uniformly doped n-type semiconductor with  $n_o = 10^{14}$   $\text{cm}^{-3}$ . The excess carrier concentration is maintained at  $2 \times 10^{18}$   $\text{cm}^{-3}$  throughout the region. (a) Calculate the Auger recombination lifetime assuming  $C_n = 2.7 \times 10^{-31}$   $\text{cm}^6 \text{sec}^{-1}$  and  $C_p = 1.1 \times 10^{-31}$   $\text{cm}^6 \text{sec}^{-1}$ . (b) If the measured lifetime in the above sample is  $4 \times 10^{-7}$  sec, determine the lifetime in the absence of Auger recombination.

Homework assignments will appear on the web at:  
<http://www.ece.udel.edu/~kolodzey/courses/eleg646s05.html>

Note: On each homework and report submission, you must please give your name, the due date, assignment number and the course number.